

共晶合金製程應用於高功率發光二極體封裝之研究

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摘要

本論文主要在探討共晶接合技術應用在高功率發光二極體(Light Emitting Diode, LED)中。薄膜製程結束後，在晶片背面再蒸鍍一層Ni/Ag金屬合金，並進行退火。在發光二極體封裝時，使用金屬接合，與一般目前市場所使用的環氧樹脂進行封裝的發光二極體進行比較。由偏壓電流在350 mA、500 mA、750 mA的熱像分析及光通量量測結果，使用共晶接合的發光二極體溫度明顯的低於使用環氧樹脂所封裝的發光二極體。除此之外，前者的光通量與後者相比較，前者較高約19.3%。測試的結果可看出，共晶接合技術應用在高功率發光二極體中的效能，明顯優於使用環氧樹脂所進行封裝的發光二極體。

關鍵詞：發光二極體、共晶接合、金屬合金、環氧樹脂

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